

# Modification of the optical constants in amorphous $\text{Sb}_2\text{Se}_3:\text{Sn}$ thin films under the illumination and heat treatment

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The optical properties of chalcogenide glasses present a great scientific interest for the establishment of the general legitimacy of interaction of the optical irradiation with the amorphous solids, as well as a practical interest. The effect of light-induced photostructural transformations in amorphous chalcogenides films have been initiated many applications of amorphous material in photonics and optoelectronics, especially as inorganic photo-resists for sub-micron technology. The optical parameters of amorphous  $\text{Sb}_2\text{Se}_3$  and  $\text{Sb}_2\text{Se}_3:\text{Sn}_x$  ( $x=0.01, 0.5, 10$  at. Sn %) prepared by vacuum evaporation on glass substrates was determined from transmission spectra. The band gap was found to be  $E_g=1.30$  eV for amorphous  $\text{Sb}_2\text{Se}_3$  and decrease with increasing of tin concentration up to  $E_g=1.0$  eV for  $\text{Sb}_2\text{Se}_3:\text{Sn}_{10.0}$ . for determination of the refractive index the approximation method proposed by Valeev was used. The maximum modifications of the refractive index under the light irradiation  $\Delta n$  ( $\Delta n=0.20$ ) occur for the composition  $\text{Sb}_2\text{Se}_3:\text{Sn}_{0.01}$ . That allows us to conclude that doping of amorphous  $\text{Sb}_2\text{Se}_3$  films with small concentrations of tin initiate the photostructural transformations under the light irradiation, and make these materials suitable for registration of optical and holographic information.

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## 1. Introduction

The optical properties of chalcogenide glasses present a great fundamental interest for the establishment of the general legitimacy of interaction of the optical irradiation with the amorphous solids, as well as a practical interest. The effect of light-induced photostructural transformations is characteristic for many amorphous chalcogenides films, and have been initiated a lot of applications of amorphous material in photonics and optoelectronics, especially as inorganic photo-resists for sub-micron technology [1]. Special interest for the applications of chalcogenide amorphous films is connected with doping with metal impurities, which alter optical, photoelectrical and transport properties of the host material [2-4]. At the same time doping of chalcogenide films by tin impurities assist in stabilizing the glassy matrix with respect to light exposure and thermal treatment [5,6].

The crystalline antimony selenide ( $\text{Sb}_2\text{Se}_3$ ) is a layer-structured semiconductor with melting temperature  $T_g=590$  °C [7]. The basic structural units are the  $\text{SbSe}_3/2$ -pyramids.  $\text{Sb}_2\text{Se}_3$  is a direct band gap semiconductor with orthorhombic crystal structure, and present a great interest due to its switching effects and its potential applications in photovoltaic [8-10]. As was found in [11], for the thermally evaporated  $\alpha$ - $(\text{Sb}_2\text{Se}_3)_{100-x}\text{Sn}_x$  thin films the thermal activation energy decreases, while the optical band gap first increase (up to  $x=1$ ) and then decrease, with the increase in Sn content. These behaviours was explained taking into account the structural modifications induced by the incorporation of Sn impurities in the host

material. The thermal activation energy  $\Delta E_a$  for pure  $\alpha$ - $\text{Sb}_2\text{Se}_3$  was estimated as  $\Delta E_a=0.42$  eV [12]. In [13] was reported the results of preparation on the base of  $\text{Sb}_2\text{Se}_3$  nanoribbons, and can be used for fabrication of high sensitive sensors due to the fact that the surface to volume ration ( $S/V$ ) is very high. The optical band gap determined from optical measurement for  $\alpha$ - $\text{Sb}_2\text{Se}_3$  was estimated  $E_g=1.15$  eV [13], and  $E_g=1.18$  eV [14]. For technological applications in solar energy conversion, and also for a wide range of optical nanodevices operating in the near infrared was proposed the low-cost  $\text{Sb}_2\text{Se}_3\text{-Sn}_x$  nanotubes [14]. Polycrystalline and amorphous  $\text{Sb}_2\text{Se}_3$  films extend the possibilities of its application in photonics and optoelectronics [15,16]. The addition of third elemental impurity such as Sn in amorphous  $\text{Sb}_2\text{Se}_3$  films can provide a pronounced effect on electrical, transport properties, optical and photoinduced phenomena [17,18]. For the  $\text{Sb}_2\text{S}_3$ ,  $\text{Sb}_2\text{Se}_3$  and  $\text{Sb}_2\text{Te}_3$  also was demonstrated the amorphous-to-crystalline phase change induced by CW  $\text{Ar}^+$  laser [19]. The photo-thermal processes is found to be responsible for the phase change in all antimony chalcogenides. It was found that the more potential candidate for use as the worm kind of storage devices is the  $\text{Sb}_2\text{Se}_3$  films, having a minimum threshold power (about  $100 \text{ W/cm}^2$ ). The chalcogenide glasses containing antimony also were investigated in order to obtain chemical microsensors and sensitive membranes for the detection of  $\text{Cd}^{2+}$  and  $\text{Cu}^{2+}$  ions in solutions [20,21]. In this paper are presented the experimental results of optical transmission spectra of thermally evaporated thin films (thickness  $\sim 1 \mu\text{m}$ ) of  $\text{Sb}_2\text{Se}_3$  and  $\text{Sb}_2\text{Se}_3:\text{Sn}_x$  ( $x=0.01, 0.5,$

10 at.%). The refractive index changes for different amorphous films in the  $\text{Sb}_2\text{Se}_3:\text{Sn}_x$  ( $x=0.01, 0.5, 10$  at. Sn %) under the light exposure and heat treatment is estimated.

## 2. Experimental

The  $\text{Sb}_2\text{Se}_3$  and  $\text{Sb}_2\text{Se}_3:\text{Sn}_x$  ( $x=0.001, 0.5$  and  $10$  at. Sn) were fabricated by “flash” thermal evaporation in vacuum ( $p=10^{-5}$  Torr) of the initial synthesized material onto the clean glass substrates. The thickness of the films was about  $d \sim 1 \mu\text{m}$ . For optical transmission a UV/VIS (300–800 nm) and 61 NIR (800–3500 nm) Specord’s CARLZEISS Jena production were used.

The influence of the light exposure on the optical transmission was examined by illumination of the samples during 1 hour by light with the intensity  $F=50000$  Lux. The thermal treating effect was examined by annealing of a part of the films in vacuum at  $T_{\text{ann}}=100$  °C during one hour. After the annealing and light exposure the optical transmission was registered in the same manner.

## 3. Results and discussion

The microscopically studies show all as-deposited  $\text{Sb}_2\text{Se}_3$  and  $\text{Sb}_2\text{Se}_3:\text{Sn}_x$  are amorphous (Fig.1a). The heat treatment and light exposure modify the morphology, some crystalline clusters appear, which are distributed non-uniformly on the sample (Fig.1b). The number and the size of clusters after the heat treatment and light exposure increase with the increasing of the concentration of tin impurity in  $\text{Sb}_2\text{Se}_3$  films.

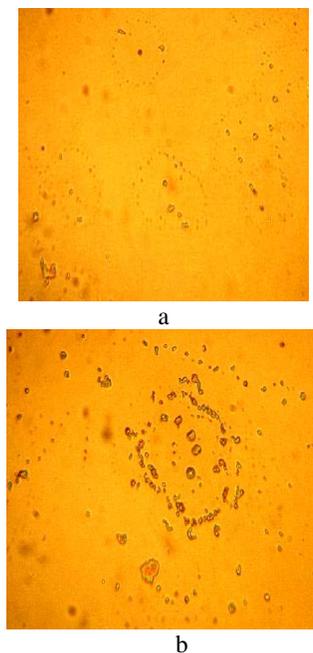


Fig.1. The morphology of the surface for the as-deposited (a) and after light exposure (b)  $\text{Sb}_2\text{Se}_3:\text{Sn}_{10}$  films.

Fig. 2 shows the transmission spectra for as-deposited amorphous  $\text{Sb}_2\text{Se}_3$  and  $\text{Sb}_2\text{Se}_3:\text{Sn}_{10}$  films. The transmission spectra for  $\text{Sb}_2\text{Se}_3:\text{Sn}_{0.01}$  and  $\text{Sb}_2\text{Se}_3:\text{Sn}_{0.5}$  is situated in the intermediate region. The optical transmission  $T$  for thin films is determined by the expression:

$$T = \frac{(1-R)^2 \exp(-kd)}{1-R^2 \exp(-2kd)}, \quad (1)$$

where  $R$  - is the optical reflection,  $k$  - the absorption coefficient, and  $d$  - the thickness of the amorphous film. In the visible region the reflection is constant and for calculations of the absorption coefficient was taken the value of about  $R = 20\%$ .

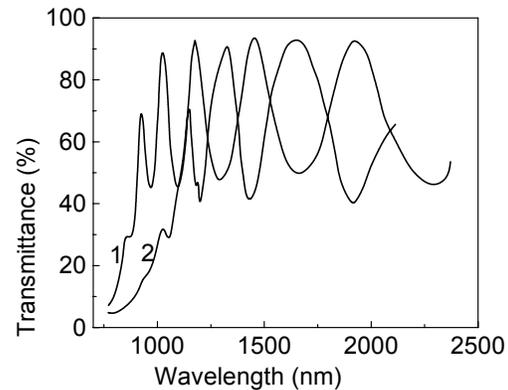


Fig.2. The transmission spectra of amorphous  $\text{Sb}_2\text{Se}_3$  (1,  $L=0.8\mu\text{m}$ ) and  $\text{Sb}_2\text{Se}_3:\text{Sn}_{10.0}$  (2,  $L=0.9\mu\text{m}$ ) thin films.

In the consideration that the member  $R^2 e^{-2\alpha d} \ll 1$  from the equation (1) we can obtain the expression for calculation of the absorption coefficient

$$\alpha = \frac{1}{d} \ln \frac{(1-R)^2}{T} \quad (2)$$

The optical band gap  $E_g$  for as-deposited amorphous films was calculated from the relation:

$$(\alpha h\nu)^{1/2} = A(h\nu - E_g), \quad (3)$$

where  $A$  - is a constant. A plot  $(\alpha \cdot h\nu)^{1/2} \sim h\nu$  (Tauc plot) yields a straight line and the extrapolation of the photon energy axis  $(\alpha \cdot h\nu)^{1/2} \rightarrow 0$  give the values of the optical band gap  $E_g$ .

The value of the optical band gap for amorphous  $\text{Sb}_2\text{Se}_3$  films was obtained  $E_g=1.3$  eV. This value for the optical band gap is in a good agreement with those obtained for the  $\text{Sb}_2\text{Se}_3$  hollow nanospheres ( $E_g=1.33$  eV) [22], and other published data for amorphous  $\text{Sb}_2\text{Se}_3$  films ( $E_g=1.25$  eV). Increasing of Sn concentration in  $\text{Sb}_2\text{Se}_3$

decrease the optical band gap, and for amorphous  $\text{Sb}_2\text{Se}_3:\text{Sn}_{10}$  films  $E_g=1.0$  eV.

For the semiconductor transparent thin film the transmission spectra, when the thickness  $d$  is comparable with the wavelength  $\lambda$  represents the curve with interference maxima and minima (Fig.2). For normal incident light the dependence of transmission  $T$  versus wavelength  $\lambda$ , the refractive index  $n$  and the thickness  $d$  mathematically can be expressed as [23]:

$$T = \frac{(1-R)^2}{1+R^2-2R\cos\delta}, \quad (4)$$

were  $\delta = \frac{4\pi}{\lambda}nd$  and  $R = \left(\frac{n-1}{n+1}\right)$ .

From (4) follow that in the transparence region of the spectra at the wavelengths

$\lambda_{\max} = \frac{4nd}{m}$ ,  $m=2, 4, 6, \dots$  we have the maximums, and

at the wavelengths  $\lambda = \frac{4nd}{m}$ ,  $m=1, 3, 5, \dots$  we have the minimums.

Than for each  $\lambda_m$  and  $\lambda_{m-1}$ , corresponding to the neighbor extremes in the transmission spectra, we can calculate the refractive index  $n$ :

$$n = \frac{\lambda_m \lambda_{m-1}}{2d(\lambda_{m-1} - \lambda_m)} \quad (5)$$

The dispersive curves of the refractive index  $n$  for amorphous  $\text{Sb}_2\text{Se}_3$  films are presented on the Fig.3. Light exposure and heat treatment increase the refractive index for  $\text{Sb}_2\text{Se}_3$ , and for amorphous films doped with tin impurities.

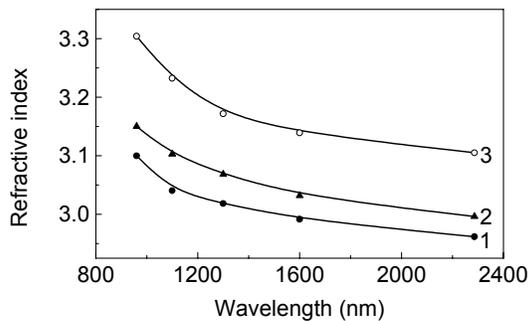


Fig.3. The dispersion curves of the refractive index for amorphous  $\text{Sb}_2\text{Se}_3$  thin films. 1 – as deposited; 2 – heat treated, 3 – illuminated

It was shown that the refractive index depends on the Sn concentration in amorphous  $\text{Sb}_2\text{Se}_3$  films, on light irradiation, and heat treatment. Fig.4 shows the dependence of the refractive index  $n$  versus Sn concentration in amorphous  $\text{Sb}_2\text{Se}_3:\text{Sn}_x$  films.

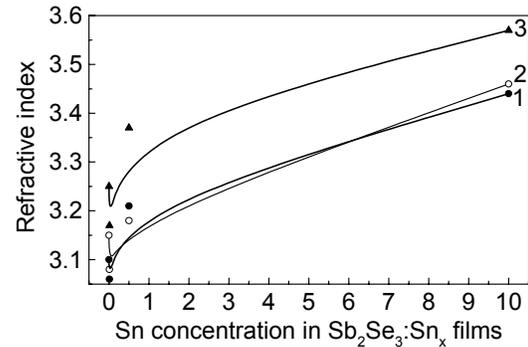


Fig.4. The dependence of the refractive index vs. Sn concentration in amorphous  $\text{Sb}_2\text{Se}_3:\text{Sn}_x$  thin films. 1 – as deposited; 2 – heat treated, 3 – illuminated.

In the wavelengths region 960÷2300 nm tin impurities (up to 0.01 at.% Sn) decrease the refractive index (Fig.4), when for the amorphous films wit tin impurities more than 0.5 at. % Sn the refractive index increases. This may be due to the formation of new structural units, and by the metallization of the atomic bonds.

The maximal modifications of the refractive index  $\Delta n$  (about  $\Delta n=0.20$ ) occur for the composition  $\text{Sb}_2\text{Se}_3:\text{Sn}_{0.01}$  and  $\text{Sb}_2\text{Se}_3:\text{Sn}_{0.05}$ . That allows us to conclude that doping of amorphous  $\text{Sb}_2\text{Se}_3$  films with small concentrations of tin initiate the photostructural transformations under light irradiation, and make these materials suitable for registration of optical information. The similar effect was observed for the amorphous Sb-Se-In films. Increasing of In atoms in Sb-Se-In films improve the optical information recording characteristics [24].

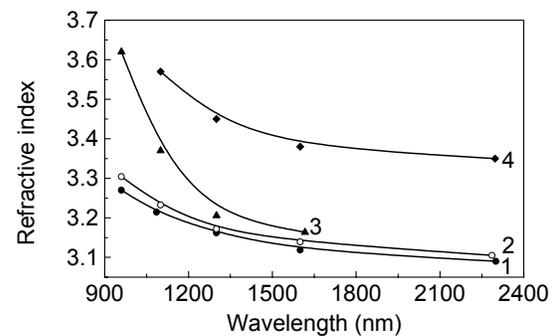


Fig.5. The dispersion curves of the refractive index for amorphous  $\text{Sb}_2\text{Se}_3$  (1),  $\text{Sb}_2\text{Se}_3:\text{Sn}_{0.01}$  (2), and  $\text{Sb}_2\text{Se}_3:\text{Sn}_{0.05}$  (3), and  $\text{Sb}_2\text{Se}_3:\text{Sn}_{10.0}$  (4) thin films.

Fig.5 shows the dependence of the refractive index  $n$  versus  $\lambda$  for all investigated amorphous films.

The effect of increasing of the refractive index under illumination and heat treatment, as was mentioned above can be used for optical storage devices with high capacities [17-19].

To initiate photostructural transformations in thin film samples a He-Ne laser ( $\lambda=0.63 \mu\text{m}$ ,  $W=10 \text{ mW}$ ) was used as a source of light exposure. The splitter was used for divide the laser beam: one Si-photodetector was used for measuring the film transmittance, and another Si-photodetector was used for measuring the time stability of the laser intensity.

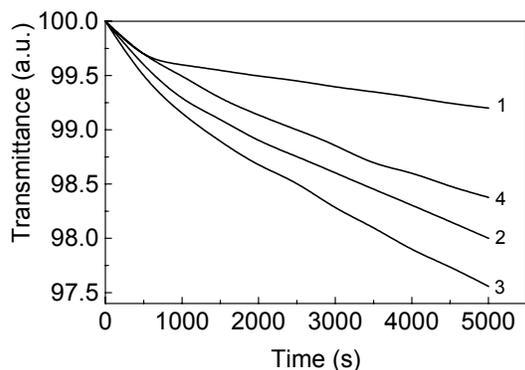


Fig.6. The kinetics of photodarkening for amorphous  $\text{Sb}_2\text{Se}_3$  (1),  $\text{Sb}_2\text{Se}_3:\text{Sn}_{0.01}$  (2), and  $\text{Sb}_2\text{Se}_3:\text{Sn}_{0.5}$  (3), and  $\text{Sb}_2\text{Se}_3:\text{Sn}_{10.0}$  (4) thin films.

The total transmittance of the film was currently measured during the exposure time with the aid of a registration module. The experimental set-up included a laser, a digital build-in PC-card for data acquisition PCI-1713A connected with the Si-photodetector. Special software was elaborated for automatic measurements.

Photocondarkening relaxation was measured during illumination for as-deposited amorphous  $\text{Sb}_2\text{Se}_3:\text{Sn}_x$ . The relaxation of the relative optical transmission  $T(t)/T(0)$  of the amorphous  $\text{Sb}_2\text{Se}_3:\text{Sn}_x$  films is shown in Fig. 6. Increasing of tin concentration up to 0.5 at.% Sn increase the photodarkening, while for the composition  $\text{Sb}_2\text{Se}_3:\text{Sn}_{10.0}$  the photodarkening decrease.

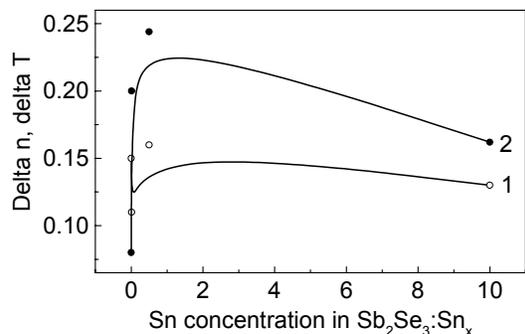


Fig.7. The concentration dependence of the change of the refractive index  $\Delta n$  under the light exposure (1) and of transmittance  $\Delta T$  (2) measured during the photodarkening process for amorphous  $\text{Sb}_2\text{Se}_3:\text{Sn}_x$  films.

Fig. 7 shows the dependence of the change of the refractive index  $\Delta n$  under the light exposure (1) and of transmittance  $\Delta T$  (2) measured during the photodarkening process for amorphous  $\text{Sb}_2\text{Se}_3:\text{Sn}_x$  films. These dependences show a good correlation, and which characterizes the sensitivity of investigated amorphous thin films to the light exposure, with the maximum around 0.5 at.% Sn.

#### 4. Summary

The optical absorption spectra of amorphous  $\text{Sb}_2\text{Se}_3$  and  $\text{Sb}_2\text{Se}_3:\text{Sn}$  thin films were used in order to determine the optical band gap and the refractive index. The modifications of the refractive index under the light exposure and heat treatment also were investigated.

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